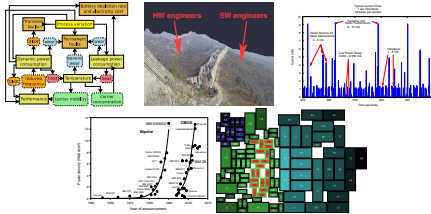


Digital Integrated Circuits – EECS 312

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Most confusing points for the week
Diodes
Homework

Policy on confusing points

If it doesn't make sense, I will either

- 1 cover it in more detail right away,
- 2 indicate when it will be covered in detail, or
- 3 invite you to office hours.

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Most confusing points for the week
Diodes
Homework

Why and when does an NMOS-based consume more power than a CMOS inverter?

- If R is big, low \rightarrow high output transition is slow.
- If R is slow, constant power consumption whenever input is high.

Derive and explain.

Most confusing points for the week
Diodes
Homework

What is leakage power consumption? What is dynamic power consumption?

- Subthreshold leakage: not a perfect switch at V_t .
- Gate leakage.
- Dynamic power.

Derive and explain.

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Most confusing points for the week
Diodes
Homework

What is the difference between a source and drain?

- Source is the side the charge carriers for the MOSFET come from.
- Drain is the side to which the charge carriers go.
- Key question: *Which terminal has a higher voltage and which terminal has a lower voltage?*

Derive and explain.

Most confusing points for the week
Diodes
Homework

Why diodes?

- In the process of building MOSFETs, we accidentally make diodes.
 - Must understand their properties.
- What we learn about device physics here will help us understand MOSFETs in later lectures.

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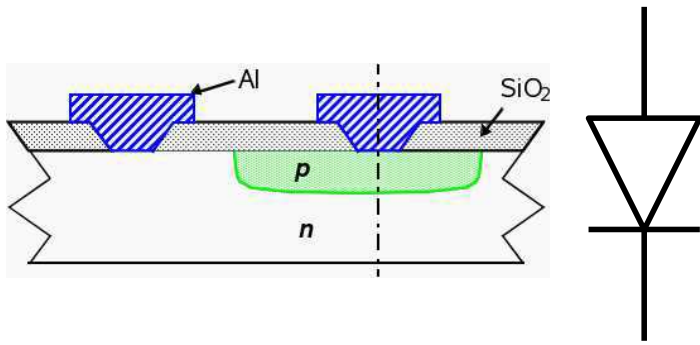
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Diode physical structure



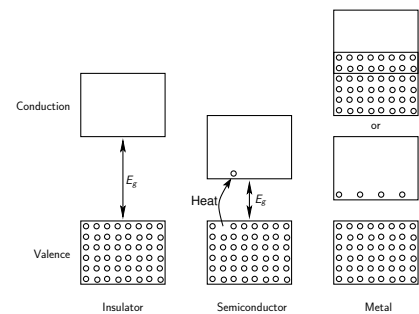
Step-by-step diode explanation

- 1 Dope regions with donors and acceptors.
- 2 N- and P-doped regions are in contact.
- 3 Diffusion according to diffusion equation.
- 4 Drift due to electrical field causes drift-diffusion effects to reach steady-state.
- 5 Left with built-in potential, and depletion region (without mobile charge carriers) near junction.
- 6 Reverse bias (making P voltage lower than N voltage) just makes depletion region bigger.
- 7 Forward bias at first reduces depletion region width, then allows mobile electrons and holes to combine at junction — sudden increase in current!
- 8 At extreme reverse bias, the few mobile carriers that get into the depletion region so fast that they collide with silicon atoms, generating electron-hole pairs, chain reaction fills depletion region with mobile carriers — sudden increase in current!

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Material properties



- Electron mobility μ_n is a bit over twice that of hole μ_p .
- Units are $\frac{\text{cm}^2}{\text{Vs}}$.

Example dopants

5	6	7	8
B	C	N	O
13	14	15	16
Al	Si	P	S
31	32	33	34
Ga	Ge	As	Se
49	50	51	52
In	Sn	Sb	Te

- Example donor: As.
- Example acceptor: B.

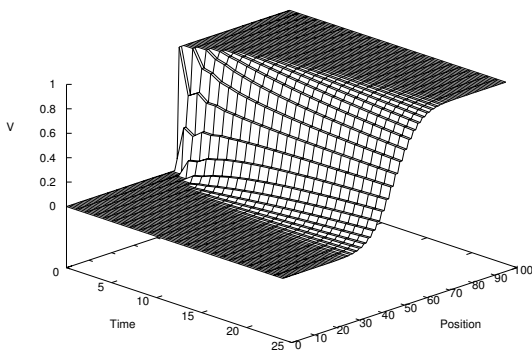
What are the electrons and holes we have been discussing?

- We mean only electrons in the conduction band, not the valence band.
- We mean only holes in the valence band, not the conduction band.
- The conduction band is mostly empty for a semiconductor.
- The valence band is mostly full for a semiconductor.

Step-by-step diode explanation

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Diffusion example



Derive and explain.

Note: Python is awesome.

Diffusion equation

$$\frac{\partial \phi(\vec{r}, t)}{\partial t} = \nabla \cdot (D(\phi, \vec{r}) \nabla \phi(\vec{r}, t))$$

- \vec{r} : location
- t : time
- $\phi(\vec{r}, t)$: density
- $D(\vec{r}, t)$: diffusion coefficient
- ∇ : vector differential operator

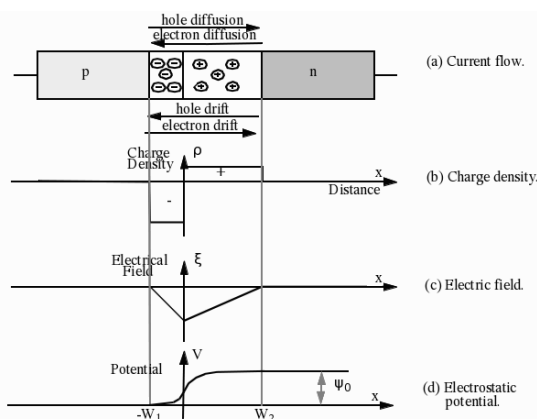
If D is constant,

$$\frac{\partial \phi(\vec{r}, t)}{\partial t} = D \nabla^2 \phi(\vec{r}, t)$$

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Junction depletion



Drift velocity

- The drift velocity $v_d = \mu \xi$, where μ is the mobility and ξ is the electric field.
- Net velocity must be small compared to particle random motion velocity for this to hold – more on this soon.

Step-by-step diode explanation

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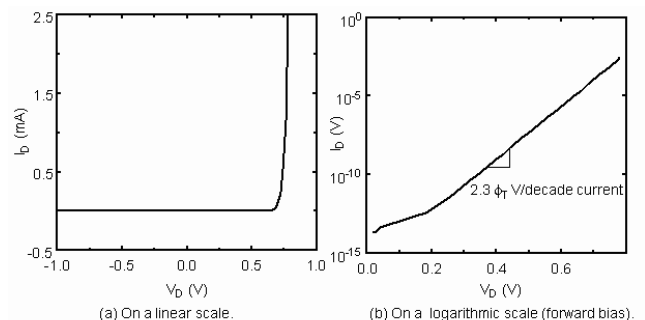
Built-in potential

$$\Phi_0 = \Phi_T \ln \left[\frac{N_A N_D}{n_i^2} \right] \quad (1)$$

$$\Phi_T = \frac{kT}{q} \quad (2)$$

- n_i : intrinsic charge carrier concentration.
- N_x : acceptor and donor concentrations.
- k : Boltzmann constant
- T : temperature
- q : elementary charge

Diode operation



$$I_D = I_S \left(e^{V_D / \phi_T} - 1 \right)$$

Diode current

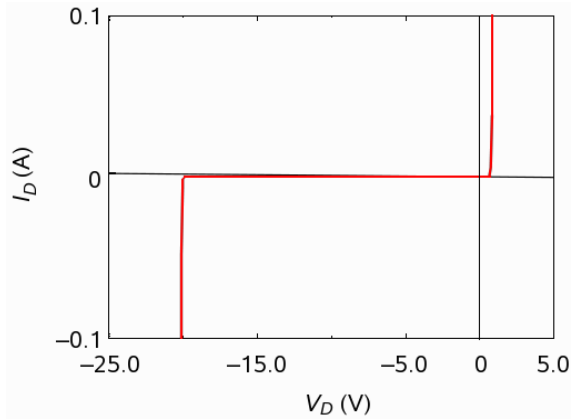
$$I_D = I_S \left(e^{\frac{V_D}{\phi_T}} - 1 \right)$$

- I_D : diode current
- V_D : diode voltage
- I_S : saturation current constant
- $\phi_T = \frac{kT}{q}$: thermal voltage
 - k : Boltzmann constant
 - T : temperature
 - q : elementary charge

Step-by-step diode explanation

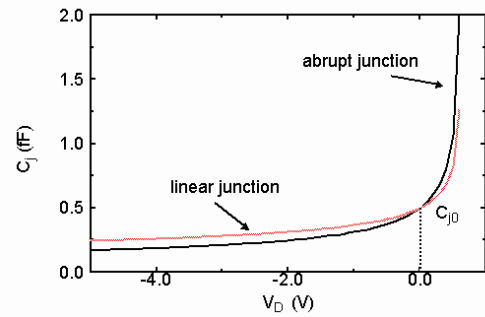
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Avalanche breakdown



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Diode capacitance



$$C_J = \frac{C_{J0}}{(1 - V_D/\Phi_0)^m}$$

$m = 0.5$ for abrupt junctions, $m = 0.33$ for linear junctions

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Diffusion capacitance

$$C_{J0} = A_D \sqrt{\frac{\epsilon_{Si} q}{2} \frac{N_A N_D}{N_A + N_D} \frac{1}{\phi_0}}$$

- A_D : area of diode
- ϵ_{Si} : permittivity of silicon
- N_X : carrier density
- $\phi_0 = \phi_T \ln \frac{N_A N_D}{n_i^2}$
 - $\phi_T = \frac{kT}{q}$
 - n_i : intrinsic carrier concentration

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Summary of basic device physics and diodes

- What are the electrons, holes, dopants, and acceptors we have been talking about?
- What are diffusion and drift?
- What is "built-in" potential?
- Avalanche breakdown?
- Intrinsic carriers?

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Upcoming topics

- Transistor static behavior.
- Fabrication.
- Transistor dynamic behavior.
- Interconnect.

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Homework assignment and announcement

- 12 September: Section 3.3.2 in J. Rabaey, A. Chandrakasan, and B. Nikolic. *Digital Integrated Circuits: A Design Perspective*. Prentice-Hall, second edition, 2003.
- 17 September: Laboratory assignment one.

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